A circuit partitioning algorithm for 3D IC designs

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ABSTRACT

The current integrated circuit design trend is towards high performance, low power, high density as well as heterogeneous integration. Traditional two-dimensional integrated circuit (2D IC) design has been unable to meet nowadays need of IC product. Hence, three-dimensional integrated circuit (3D IC) is emerging as an effective way for overcoming the barriers in 2D IC design. In Taiwan, 3D IC technology has also become a very important and hot issue for IC design companies. 3D IC needs 3D chip architecture to implement the whole design. That is, the whole circuit must be divided into several subsystems, and each one should be implemented on single layer of die. 3D IC chip can thus be formed by stacking these layers of dice vertically. Besides considering chip manufacture cost same as 2D, 3D chip cost also consists of die stacking cost, stacking yield, TSV(through-silicon-via) cost and TSV yield to reflect heat dissipation and TSV insertion problems. To meet the goal of 3D IC design, in this thesis, based on 3D cost evaluation function, a 3D IC circuit partitioning procedure considering TSV minimization is proposed. The experimental results show that the proposed algorithm demonstrates the improvements on the minimization of TSV.

Keywords: 3D IC, circuit partitioning, TSV

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